

Mark Name	Logo	TM Application Status	Country
300WORKS	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
A (stylized)	®	Registered	Australia Benelux Brazil Canada China European Union France Germany (Federal Republic of) Hong Kong India Indonesia Ireland (Republic of) Israel Italy Japan Korea, Republic of (KR) Malaysia Mexico Philippines Russian Federation Singapore Spain Sweden Switzerland Taiwan

A (stylized)	®	Registered	Thailand United Arab Emirates United Kingdom United States of America
A (stylized) (with Cropped Banner Device)	®	Registered	China
A APPLIED MATERIALS (stylized in centered presentation)	®	Registered	China
A APPLIED MATERIALS (stylized)	®	Registered	China Thailand United States of America
A APPLIED MATERIALS MAKE POSSIBLE (stylized)	™	Application	China
ACCESS	®	Registered	Taiwan
	®	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
ACENTA	®	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
ACTIVITY MANAGER	™	Allowed Application	China
	®	Registered	International Japan Korea, Republic of (KR) United States of America
Acuity	™	Application	China
	®	Registered	China European Union International Japan

Acuity	® ™	Registered Allowed Application	Singapore United States of America Korea, Republic of (KR) Taiwan
ADEN	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
ADVENT	®	Registered	Taiwan
AdvisorMV	®	Registered	European Union United Kingdom
AERA	®	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore
AERIS	®	Registered	United States of America Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AF-Mag	™ ®	Application Registered	European Union Benelux China Czechia Finland France Germany (Federal Republic of) Hungary India International Italy Japan Korea, Republic of (KR)

AF-Mag	®	Registered	Liechtenstein Poland Portugal Spain Sweden Switzerland Taiwan Turkey United Kingdom
AI Design Forum	®	Registered	United States of America
AI(X)	®	Registered	European Union International Israel Japan Singapore Taiwan
	™	Allowed Application	United States of America China
AIDF	®	Registered	United States of America
AITHION	®	Registered	Australia Canada China European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan
	™	Allowed	United Kingdom United States of America
AIX	®	Registered	European Union International Israel Japan Korea, Republic of (KR)

AIX	®	Registered	Singapore Taiwan
	™	Allowed Application	United States of America China
AJAX	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
AKT	®	Registered	China Germany (Federal Republic of) Ireland (Republic of) Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
	™	Application	China International
AKTIV	®	Registered	United States of America
	™	Application	China
ALPS	®	Registered	United States of America
ALTA	®	Registered	France Germany (Federal Republic of) United States of America
Alteza	™	Application	Taiwan United States of America
		To Be Filed	International
ALTUM	®	Registered	Australia Canada China European Union International Israel Japan

ALTUM	®	Registered	Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom
AMAT	™	Allowed	United States of America
AMPLIPHI	®	Registered	Benelux
	®	Registered	China Korea, Republic of (KR) Taiwan
	™	Allowed Application	United States of America Japan
		To Be Filed	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
APF	®	Registered	United States of America
APF FUSION	®	Registered	United States of America
APF RTD	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom
APOLLO	®	Registered	United States of America Japan
	™	Allowed	United States of America Taiwan
APPLIED	®	Published Registered	Korea, Republic of (KR) Benelux Japan

APPLIED AERIS	®	Registered	China
APPLIED AERIS-G	®	Registered	China
	™	Published	China
Applied AI(X)	™	Allowed	United States of America
APPLIED CHARGER	®	Registered	United States of America
APPLIED E3	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
APPLIED ENDURA IMPULSE	®	Registered	Japan Korea, Republic of (KR) Taiwan
APPLIED FABVANTAGE	®	Registered	United States of America
Applied Forecast Parts Management	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
APPLIED GLOBAL SERVICES	®	Registered	United States of America
Applied Managed Service	®	Registered	International Japan Taiwan United States of America
APPLIED MATERIALS	®	Registered	Australia Benelux Brazil Canada China European Union France Germany (Federal Republic of) Hong Kong India

APPLIED MATERIALS	®	Registered	Indonesia International Ireland (Republic of) Israel Italy Japan Korea, Republic of (KR) Malaysia Mexico Philippines Russian Federation Singapore Spain Sweden Switzerland Taiwan United Arab Emirates United Kingdom United States of America
APPLIED MATERIALS A (stylized) (with Blue Banner Device)	™	Application	China
	®	Registered	China
APPLIED MATERIALS A (stylized) and Chinese Characters	™	Published	China
APPLIED MATERIALS A (stylized) and Chinese Characters (with Rounded Rectangle Device)	®	Registered	China
APPLIED MATERIALS and Japanese Characters	®	Registered	Japan
APPLIED MATERIALS, INC	®	Registered	China
APPLIED MOSAIC	™	Application	United States of America
Applied Nanophotonics	™	Application	United States of America
APPLIED OLYMPIA	®	Registered	Japan
APPLIED OLYMPIA ALD	®	Registered	Japan
Applied OnDemand	®	Registered	International Japan Taiwan United States of America
APPLIED OPUS	™	Application	China
APPLIED PERFORMANCE SERVICE	®	Registered	United States of America
	®	Registered	International Japan

APPLIED PERFORMANCE SERVICE	®	Registered	Korea, Republic of (KR) Taiwan United States of America
APPLIED SANSА	®	Registered	China
APPLIED SMARTFACTORY	®	Registered	European Union International Japan Singapore Taiwan United Kingdom United States of America
APPLIED SMARTFACTORY RX	®	Registered	China Taiwan
APPLIED THERMION	®	Registered	Japan Taiwan
APPLIED VENTURES	®	Registered	United States of America
AppliedAI(X) (stylized with superscript)	®	Registered	Canada European Union International Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom United States of America
appliedmaterials.tw	™	Allowed Application	Malaysia
AppliedPRO	®	Registered	Taiwan
	®	Registered	Canada European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland

AppliedPRO	®	Registered	Taiwan United States of America
AppliedTwin	® ™	Registered Application	International China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
ARAGON	®	Registered	China International Japan Korea, Republic of (KR) Singapore Taiwan
arCADE	™ ™	Allowed Application To Be Filed	United States of America United States of America China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan
ArchitectMV	®	Registered	United Kingdom
Arian	® ™	Registered Application	International China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan
ARISTO	®	Registered	United States of America
ARNO	®	Registered	Germany (Federal Republic of) China

ARNO	®	Registered	International Japan Korea, Republic of (KR) Singapore Taiwan
AthenaAI	™ ®	Allowed Registered	United States of America European Union International Israel Japan Singapore United States of America
AUTOMOD	™ ®	Application Registered	Taiwan European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AUTOSCHED	™ ®	Published Registered	China China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
AVATAR	®	Registered	China United States of America
AVENIR	®	Registered	United States of America
AVILA	™	Allowed	United States of America
AVINA	®	Registered	China European Union International Japan

AVINA	®	Registered	Korea, Republic of (KR) Taiwan United Kingdom United States of America
AXCELA	®	Registered	China European Union Singapore
	™	Application	International Japan Korea, Republic of (KR) Malaysia Taiwan
AXIOM	®	Published	United States of America
B (stylized)	®	Registered	United States of America Australia Belarus China Croatia European Union Hong Kong India International Italy Japan Korea, Republic of (KR) Norway Russian Federation Serbia Singapore Switzerland Taiwan Turkey Ukraine United Kingdom United States of America Vietnam
BACCINI (stylized)	®	Registered	Australia Belarus

BACCINI (stylized)	®	Registered	China Croatia European Union Hong Kong India International Italy Japan Korea, Republic of (KR) Norway Russian Federation Serbia Singapore Switzerland Taiwan Turkey Ukraine United Kingdom United States of America Vietnam
BatchMV	®	Registered	United Kingdom
BioAPC	®	Registered	Singapore United Kingdom
BioMV	™	Allowed	United States of America
BIONEURON	®	Registered	United Kingdom
BLACK DIAMOND	®	Registered	United Kingdom Japan United States of America
BLACKHAWK	®	Registered	China Korea, Republic of (KR) Taiwan United States of America
BLACKSTONE	®	To Be Filed Registered	Taiwan China International Japan Korea, Republic of (KR) Taiwan

BLACKSTONE	®	Registered	United States of America
BLAZER	®	Registered	United States of America
Bridge	®	Registered	International
	™	Application	China
			European Union
			Israel
			Japan
			Korea, Republic of (KR)
			Singapore
			Taiwan
			United States of America
CARINA	®	Registered	United States of America
CATALYST	®	Registered	European Union
			International
	™	Allowed	United States of America
		Application	China
			Japan
			Korea, Republic of (KR)
			Singapore
			Taiwan
CELLWORKS	®	Registered	Singapore
			United Kingdom
			United States of America
CENTINEL	®	Registered	United States of America
CENTRIS	®	Registered	China
			United States of America
CENTURA	®	Registered	Benelux
			China
			European Union
			France
			Germany (Federal Republic of)
			Hong Kong
			India
			Indonesia
			Ireland (Republic of)
			Israel
			Italy
			Japan

CENTURA	®	Registered	Korea, Republic of (KR) Singapore Spain Sweden Switzerland Taiwan United Kingdom United States of America
CENTURA (and Katakana version)	®	Registered	Japan
CENTURA WXP	®	Registered	Singapore Taiwan
ChamberAI	®	Registered	Canada European Union International Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United States of America
ChamberTwin	™ ® ™	Application Registered Application	China International China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Ciena	®	Registered	United States of America
CLARA	®	Registered	United States of America China International Korea, Republic of (KR)
CLARION	™ ®	To Be Filed Registered	United States of America China European Union International

CLARION	®	Registered	Korea, Republic of (KR) Singapore Taiwan
CLARIPHI	®	Registered	United States of America China Korea, Republic of (KR) Taiwan
CLASS MCS 5	™ ®	Allowed Registered	United States of America Japan China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
CLEAN MODE	™	Application	United States of America Malaysia
CLEANCOAT	®	Registered	United Kingdom
CLERE	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America Canada China European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Taiwan
CloudSim	™ ®	Allowed Registered	United States of America European Union International Singapore

CloudSim	® ™	Registered Allowed Application	Taiwan United States of America China Japan Korea, Republic of (KR)
CLOVER	®	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
CONFORMA	®	Registered	Taiwan
Contorno	® ™	Registered Application	International China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Contour	™	Allowed	United States of America
ControlMV	®	Registered	United Kingdom
CORNERSTONE	®	Registered	United Kingdom
CORONA UV	®	Registered	Korea, Republic of (KR) Taiwan
CORSA	®	Registered	Australia Canada China European Union Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan

CORSA	®	Registered	United Kingdom United States of America
	™	Application	International
CRION	®	Registered	United States of America
CrossMatch	®	Registered	United States of America
Cupryx	®	Registered	China European Union International Japan Singapore Taiwan
	™	Allowed	United States of America Korea, Republic of (KR) Korea, Republic of (KR) Taiwan
DARC	®	Application Registered	United States of America United States of America International
DESICA	®	Registered	International
DeviceTwin	®	Registered	China European Union Japan Korea, Republic of (KR) Singapore Taiwan
	™	Application	United States of America United States of America International
Digital Dynamic Connection	®	Registered	China Japan Korea, Republic of (KR) Singapore Taiwan
	™	Application	United States of America International
DIMENSION	®	Registered	China France Germany (Federal Republic of) International Israel

DIMENSION	®	Registered	Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
DMO SYSTEMS	®	Registered	Taiwan
DPS	®	Registered	China European Union Korea, Republic of (KR) Singapore United Kingdom United States of America
DPS CENTURA	®	Registered	Benelux France Germany (Federal Republic of) Hong Kong Indonesia Ireland (Republic of) Italy Japan Korea, Republic of (KR) Singapore Spain Sweden United Kingdom United States of America
DRACO	™ ®	Published Registered	Taiwan International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
DROSSA	™ ®	Application Registered	China China International Japan

DROSSA	®	Registered	Korea, Republic of (KR) Taiwan
DSF	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
DURASOURCE	™	Allowed	United States of America
DURUM	®	Registered	United States of America
	®	Registered	China European Union International Japan Korea, Republic of (KR) Malaysia Singapore Taiwan
EcoTwin	®	Registered	United States of America European Union International Singapore Taiwan
	™	Application	United States of America China Japan
ecoUP	™	Application	Korea, Republic of (KR) China International Israel Japan
		To Be Filed	Korea, Republic of (KR) Singapore Taiwan United States of America China International

ecoUP	™	To Be Filed	Israel Japan Korea, Republic of (KR) Singapore Taiwan
EduTwin	® ™	Registered Application	International China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Elevated Materials	® ™	Registered Allowed Application	International United States of America China European Union Japan Korea, Republic of (KR) Singapore Taiwan
Eli	® ™	Registered Allowed Application	International United States of America China European Union Japan Korea, Republic of (KR) Singapore Taiwan
ELLUMINATOR	® ™	Registered Application	European Union International Japan United Kingdom United States of America China Korea, Republic of (KR) Taiwan

EMAX	®	Registered	United States of America
ENDURA	®	Registered	Benelux China European Union France Germany (Federal Republic of) Hong Kong India Indonesia Ireland (Republic of) Israel Italy Japan Korea, Republic of (KR) Singapore Spain Sweden Switzerland Taiwan United Kingdom United States of America
ENDURA CIRRUS	®	Registered	China European Union International Singapore Taiwan United States of America
ENDURA IMPULSE	™	Allowed Application	Japan Korea, Republic of (KR)
ENFLEXOR	®	Registered	China
ENGINEEREDWORKS	™	Allowed	United States of America
	®	Registered	United States of America
	®	Registered	European Union Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom

ENGINEEREDWORKS	®	Registered	United States of America
	™	Application	International
EngineeringTwin	®	Registered	International
	™	Application	China
			European Union
			Japan
			Korea, Republic of (KR)
			Singapore
			Taiwan
			United States of America
ENLIGHT	®	Registered	United States of America
	™	Application	China
			Israel
			Japan
			Korea, Republic of (KR)
			Taiwan
		Published	European Union
			Singapore
ENZO	®	Registered	China
			European Union
			International
			Japan
			Korea, Republic of (KR)
			Singapore
			Taiwan
	™	Allowed	United States of America
EPIC	™	Application	China
			European Union
			International
			Japan
			Korea, Republic of (KR)
			Singapore
			Taiwan
			United States of America
Epic Center	™	Application	China
			European Union
			International
			Japan

Epic Center	™	Application	Korea, Republic of (KR) Singapore Taiwan
ERGON	®	Registered	United States of America China International Japan Korea, Republic of (KR) Singapore Taiwan
ESATTO AOI	™	Allowed	United States of America
ESATTO HP kit	®	Registered	China Taiwan
ESATTO HP+	®	Registered	China Taiwan
ESATTO SEm	®	Registered	China Taiwan
ESATTO TECHNOLOGY	®	Registered	China Korea, Republic of (KR) United States of America
ESCOSYS	®	Registered	Austria Benelux China France Germany (Federal Republic of) International Italy Japan Korea, Republic of (KR) Switzerland United Kingdom
ETERNA	®	Registered	China United States of America
ETERNA FCVD	™	Application	Korea, Republic of (KR) Taiwan
ETERNA FCVD	®	Registered	Taiwan

ETERNA FCVD	®	Registered	United States of America
ETERNA TRINITY	®	Registered	United States of America
EVEREST	®	Registered	International
	™	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
EXECTA	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
EXPRESS EXCHANGE	®	Registered	United States of America
ExtractAI	®	Registered	United States of America China European Union International Israel Japan Korea, Republic of (KR) Singapore
EYED	™	Application	United States of America
FAB300	®	Registered	United States of America
	®	Registered	Australia Benelux France Germany (Federal Republic of) Israel United States of America
FabOptimizer	®	Registered	United States of America
FACTORYWORKS	®	Registered	China European Union International Japan

FACTORYWORKS	®	Registered	Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
FCVD	®	Registered	China International Japan Korea, Republic of (KR) Malaysia Taiwan United States of America
FERMI	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
FINE LINE DOUBLE PRINTING	®	Registered	United States of America
FLDP	®	Registered	United States of America China Korea, Republic of (KR) Taiwan United States of America
FLDP (Chinese Characters)	®	Registered	China Taiwan
FLDP (in simplified Chinese characters)	®	Registered	China
FleetTwin	®	Registered	International
	™	Application	China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Forma	®	Registered	International
	™	Application	China European Union Israel Japan

Forma	™	Application	Korea, Republic of (KR) Singapore Taiwan
FormulateAPC	®	Registered	United States of America United Kingdom
FormulateMV	®	Registered	United Kingdom
Fortis	®	Registered	European Union International Singapore Taiwan
	™	Allowed Application	United States of America China Japan
Forza	™	Application To Be Filed	Korea, Republic of (KR) United States of America China European Union International Japan
FULLVISION	®	Registered	Korea, Republic of (KR) Singapore Taiwan
GARNET	®	Registered	United States of America
GEBI	™	Allowed	Korea, Republic of (KR)
	®	Registered	United States of America Canada China European Union International Israel Japan
GINESTRA	®	Registered	Korea, Republic of (KR) Singapore Switzerland United Kingdom United States of America Canada China

GINESTRA	®	Registered	European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom United States of America
GUARDIAN	®	Registered	United States of America
HARP	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
HawkEye	®	Registered	European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
HEADSMART	™ ®	Allowed Registered	United States of America China European Union International Japan Korea, Republic of (KR) Malaysia Singapore Taiwan United Kingdom United States of America
HIRES	®	Registered	China Germany (Federal Republic of)

HIRES	®	Registered	India International Italy Japan Korea, Republic of (KR) United States of America
HydroClean	®	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
HydroCoat	®	Registered	European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
HyperSense	®	Registered	European Union International United States of America
	™	Allowed Application	United States of America Israel Japan Korea, Republic of (KR) Taiwan
IC^N	™	Published Application	Singapore United States of America
ICT	®	Registered	Germany (Federal Republic of)
ICT (and Design)	®	Registered	Germany (Federal Republic of) United Kingdom United States of America
IMAP	®	Registered	United States of America
IMPULSE	®	Registered	China European Union Korea, Republic of (KR)

IMPULSE	®	Registered	Taiwan United Kingdom
IMS	® ™	Registered Application	International China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Indigo	®	Registered	European Union International Singapore Taiwan
	™	Application	China Japan Korea, Republic of (KR) United States of America
Insepra	®	Registered	China European Union International
	™	Allowed Application	Taiwan United States of America Japan Korea, Republic of (KR) Singapore
INSTAVISION	®	Registered	China International Korea, Republic of (KR) Singapore Taiwan United States of America
INTEGRATED MATERIALS SOLUTION	®	Registered	International Japan United States of America
	™	Application	Korea, Republic of (KR) Singapore

Intenza	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
INVIA	™ ®	Allowed Registered	United States of America European Union Korea, Republic of (KR) Taiwan United Kingdom United States of America
IONIQ	™ ®	Application Registered	China Japan China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
IRIS	™ ®	Application Registered	Singapore International Singapore United States of America
ISANI	™	Application	European Union Japan Korea, Republic of (KR) Taiwan
ISCAN	®	Registered	United States of America
ISYSTEM	®	Registered	United States of America China International Japan Korea, Republic of (KR)

ISYSTEM	®	Registered	Taiwan United States of America
iSystem Foresight	™ ®	Application Registered	European Union European Union International Israel Japan Korea, Republic of (KR) Singapore Switzerland United States of America Canada Malaysia
KEYSTONE	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
KINEX	®	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
KODIAK	™ ®	Application Registered	China International Korea, Republic of (KR) Taiwan United States of America
LAVACOAT	®	Registered	United States of America
LDS	® ™	Registered Application	International China European Union Japan

LDS	™	Application	Korea, Republic of (KR) Singapore Taiwan
LEAD	®	Registered	United States of America Germany (Federal Republic of) India International Japan Korea, Republic of (KR) Taiwan
Leopard	™	To Be Filed	United States of America
	®	Registered	International
	™	Application	China European Union Japan Korea, Republic of (KR) Singapore Taiwan
Leviaxis	®	Registered	United States of America Germany (Federal Republic of)
LeviDrive	®	Registered	Germany (Federal Republic of)
LeviMotion	®	Registered	Germany (Federal Republic of)
LIMITLESS EDGE	®	Registered	Benelux International Sweden Switzerland United Kingdom
LINK	™	Allowed Application	United States of America India
	®	Published	Singapore
	®	Registered	United States of America
Lion	®	Registered	International
	™	Application	China European Union Japan Korea, Republic of (KR) Singapore Taiwan

Lion	™	Application	United States of America
Lucent	™	Application Application To Be Filed	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
Lynx	® ™	Registered Application	International China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Magnus	™	Application	Taiwan United States of America
MAKE POSSIBLE	®	Registered	United States of America European Union Japan Korea, Republic of (KR) Malaysia Singapore United Kingdom
MARANGONI	®	Registered	United States of America China Germany (Federal Republic of) Japan
MARATHON	®	Registered	Korea, Republic of (KR)
MDLx	®	Registered	Canada China European Union International Israel Korea, Republic of (KR) Malaysia Singapore

MDLx	®	Registered	Switzerland Taiwan United Kingdom United States of America
Mecatronicx	™	Application	Japan
Mimansa	®	Registered	Germany (Federal Republic of) European Union International
	™	Allowed Application	United States of America India Japan Korea, Republic of (KR) Singapore
Mimansa AI	®	Registered	European Union International
	™	Allowed Application	United States of America India Japan Korea, Republic of (KR) Singapore
MIRRA	®	Published Registered	China European Union Hong Kong India Indonesia Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
MIRRA (and Design)	®	Registered	European Union United Kingdom
MIRRA MESA	®	Registered	Korea, Republic of (KR) United States of America
ModuleTwin	®	Registered	International
	™	Application	China

ModuleTwin	™	Application	European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Momentum Fund	® ™	Registered Application	International Canada China European Union India Israel Japan Korea, Republic of (KR) Malaysia Philippines Singapore Taiwan United Kingdom United States of America
monitorMV	®	Registered	United Kingdom
monitorMV (and Design)	®	Registered	United Kingdom
Morpher	® ™	Registered Application	European Union International China Japan Korea, Republic of (KR) Singapore Taiwan United States of America
MUSTANG	®	Registered	United States of America
NANOCURE	®	Registered	International Korea, Republic of (KR) United States of America
NEMA	® ™	Registered Application	European Union United States of America China Japan

NEMA	™	Application	Taiwan
NEOX	™	Allowed	United States of America
NEPTUNE	®	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
Net Zero 2040 Playbook	™	Application To Be Filed	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
NetConnect	®	Registered	European Union International
	™	Allowed Application	United States of America China Israel Japan Korea, Republic of (KR) Singapore Taiwan
NEW ARISTO	®	Registered	China European Union Germany (Federal Republic of) Japan Korea, Republic of (KR) Taiwan United Kingdom
NEW ARISTO (in Chinese characters)	®	Registered	China
NEXUS-E	®	Registered	China European Union Germany (Federal Republic of)

NEXUS-E	®	Registered	India Indonesia International Japan Korea, Republic of (KR) United Kingdom United States of America
NOKOTA	®	Registered	United States of America
NUCLEON	®	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan
	™	Allowed Application	United States of America
NutriAPC	®	Registered	China United Kingdom
NutriMV	®	Registered	China International Singapore United Kingdom United States of America
OLYMPIA	®	Registered	European Union International Taiwan United Kingdom United States of America
ONYX	®	Registered	United States of America
OPTA	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
OPTIKON	®	Registered	United States of America United Kingdom
OPTIVA	®	Registered	United States of America

OPTOPLEX	®	Registered	Benelux China France Germany (Federal Republic of) International Italy Switzerland Taiwan United Kingdom
Palisade	®	Registered	European Union International Japan Singapore Taiwan
	™	Allowed Application	United States of America China
PALOMAR	®	Published	Korea, Republic of (KR)
Panorama	®	Registered	United Kingdom
	™	Application	International China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan
PAT-NAV Pat-Nav PatNav Pat Nav PAT NAV	®	Registered	United States of America United Kingdom
PERCEPTIVE ENGINEERING	®	Registered	Singapore United Kingdom
Perceptive Engineering	®	Registered	United Kingdom
PerceptiveAPC	®	Registered	China International Singapore United Kingdom
PerformAPC	™	Published	United States of America
PerformMV	®	Registered	United Kingdom
	®	Registered	United Kingdom

PharmaAPC	®	Registered	United Kingdom
PharmaMV	®	Registered	China International Singapore United Kingdom United States of America
PharmaNeuron	®	Registered	United Kingdom
PharmaVision	™	Application To Be Filed	United States of America China European Union International Japan Korea, Republic of (KR) Singapore
PIKA	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
PIONEER	®	Registered	China European Union International Israel Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom United States of America
PISCES	™	Application	Japan Malaysia
PIVOT	®	Registered	United Kingdom China Germany (Federal Republic of) International

PIVOT	®	Registered	Japan Korea, Republic of (KR) Taiwan
PiVot “樞紐” (Chinese translation of the meaning of PiVot)	®	Registered	Taiwan
PiVot ”樞紐” (Chinese translation of the meaning of PiVot)	®	Registered	China
Pixel Blending	®	Registered	International
	™	Application	China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
POLARIS	®	Registered	European Union International Israel Korea, Republic of (KR) Singapore Taiwan United States of America
	™	Allowed Application	Japan
Polestar	®	Registered	International
	™	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
PRECISION	®	Registered	China International Japan Taiwan United States of America
	™	Application	China
PRECISION 5000	®	Registered	Benelux France

PRECISION 5000	®	Registered	Hong Kong Indonesia Ireland (Republic of) Israel Italy Singapore Spain Switzerland Taiwan United States of America
PRECISION CVD	™	Published	China
Premus	™	Application To Be Filed	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
PRESIDIO	®	Registered	Canada China European Union International Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom United States of America
PRESTO	®	Registered	China
PRIME	®	Registered	International Singapore
PRIMEVISION	™	Application	United States of America
	®	Registered	China European Union International

PRIMEVISION	®	Registered	Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
PRISTINE	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
PRIZM	®	Registered	United States of America
PROAnalytics	®	Registered	International
	™	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
ProcessTwin	®	Registered	International
	™	Application	European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
PRODUCER	®	Registered	European Union Japan Taiwan United Kingdom United States of America
PRODUCER KODIAK	®	Registered	China
PRODUCER NANOCURE	®	Registered	China
PRODUCER ONYX	®	Registered	China Japan Korea, Republic of (KR)

PRODUCER ONYX	®	Registered	Taiwan United States of America
PRODUCER XP PRECISION	®	Registered	China Korea, Republic of (KR)
PROMIS	™	Published	China
PROMOTO	®	Registered	United States of America International Korea, Republic of (KR) Taiwan United States of America
Pronto	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
PROSight	™	Allowed	United States of America
PROVISION	®	Registered	China European Union International Israel Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
pSynapse	®	Registered	United Kingdom
PURITY	®	Registered	Japan Korea, Republic of (KR) Taiwan United States of America
PYRA	®	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom

PYRA	®	Registered	United States of America
QbDD	®	Registered	United Kingdom
QUANTUM	®	Registered	United States of America
QUICKSTART	®	Registered	China European Union International Israel Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
RADIANCE	®	Registered	China European Union International Japan Switzerland United Kingdom United States of America
RADION	™	Application	European Union
	®	Registered	United States of America
RAIDER	™	Published	China
	®	Registered	European Union United Kingdom United States of America
RAPTOR	®	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
REFLEXION	®	Registered	European Union Japan Korea, Republic of (KR) Taiwan United Kingdom

REFLEXION	®	Registered	United States of America
RETICLEAN	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
RETIGUARD	®	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
Reveal	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
ROSSA	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
RT Manager	®	Registered	International Singapore United Kingdom United States of America
SACVD	®	Registered	Japan United States of America
SAFARI	®	Registered	European Union International Korea, Republic of (KR)

SAFARI	®	Registered	Singapore Taiwan
Sana	™	Allowed	United States of America
	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
SANSA	™	Allowed	United States of America
	®	Registered	China Korea, Republic of (KR) United States of America
	™	Application	Korea, Republic of (KR) Taiwan
SAPHIRA	®	Registered	China International Japan Korea, Republic of (KR) Taiwan
	™	Application	United States of America
SCULPTA	®	Registered	Malaysia European Union International Japan Korea, Republic of (KR) Singapore Taiwan
	™	Application	United States of America
SELECTRA	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom

SELECTRA	®	Registered	United States of America
	™	Application	China
SELFI	®	Registered	European Union
			International
			Israel
			Korea, Republic of (KR)
			Singapore
			Taiwan
	™	Allowed	United States of America
		Application	China
			Japan
SemiGuru	™	Application	China
			European Union
			International
			Israel
			Japan
			Korea, Republic of (KR)
			Singapore
			Taiwan
			United States of America
SEMITOOL	®	Registered	Benelux
			Canada
			China
			European Union
			Ireland (Republic of)
			Japan
			Korea, Republic of (KR)
			Singapore
			United Kingdom
			United States of America
SEMVision	®	Registered	China
			European Union
			International
			Israel
			Japan
			Korea, Republic of (KR)
			Taiwan
			United Kingdom

SEMVision	®	Registered	United States of America
SICONI	®	Registered	United States of America
SideView	®	Registered	China European Union International Israel Japan Singapore
	™	Allowed Application	United States of America
SIGMAMELTEC (and Design) (English and Japanese characters)	®	Registered	Korea, Republic of (KR) China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
SIGNET	®	Registered	Canada China European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan
	™	Allowed Application	United States of America Canada Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan

SILENA	®	Registered	China European Union International Israel Korea, Republic of (KR) Malaysia Singapore Taiwan United Kingdom United States of America
SILVIA	®	Registered	United States of America
SINGEN & DESIGN	®	Registered	United States of America
SIP ENCORE	®	Registered	United States of America
SIXTHSENSE	®	Registered	China Korea, Republic of (KR)
	™	Application	Korea, Republic of (KR) Taiwan
SLD	®	Registered	European Union International United States of America
	™	Allowed Application	Japan Korea, Republic of (KR) Singapore Taiwan
SLIMCELL	®	Registered	United States of America
SMARTFACTORY	®	Registered	United States of America
SMARTFACTORY RX	®	Registered	European Union International Japan Singapore United Kingdom United States of America
SMARTSCHED	®	Registered	United States of America
SMARTSTART	®	Registered	Korea, Republic of (KR) United States of America
SmartWeb	™	Published	Japan
	®	Registered	Benelux China

SmartWeb	®	Registered	France Germany (Federal Republic of) International Italy Japan Korea, Republic of (KR) Taiwan United Kingdom
SOFT LINE (Chinese Characters)	®	Registered	China
SOFT LINE (in Chinese characters)	®	Registered	China European Union Taiwan
Solance	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
SOLION	™ ®	Allowed Registered	United States of America China Japan Taiwan
SONETTO	®	Registered	United States of America China
SPC3D	®	Registered	European Union International Japan Singapore United States of America
Sprinter	™ ®	Application Registered	China European Union International
	™	Application	China Japan Korea, Republic of (KR) Singapore Taiwan

Sprinter STARK	™ ®	Application Registered	United States of America International Korea, Republic of (KR) Taiwan
STATIONWORKS STELLA	™ ® ®	Application To Be Filed Registered Registered	China United States of America United States of America European Union International Korea, Republic of (KR) Singapore Taiwan
STENSAR	™ ®	Allowed Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
SuperScan	™ ®	Allowed Registered	United States of America European Union International Japan Singapore
SYM3	™ ®	Application Registered	United States of America China Korea, Republic of (KR) Taiwan China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom
Sym3 Y Magnum	™	Application	United States of America Taiwan

Sym3 Y Magnum	™	Application	United States of America
SYM3D	®	Registered	China Japan Korea, Republic of (KR) Taiwan
SYNEXIS	®	Registered	United States of America United Kingdom
TANGO	®	Registered	China European Union Singapore
	™	Application	United States of America International Japan Korea, Republic of (KR) Malaysia Taiwan
TANGO SYSTEMS	®	Registered	China European Union Singapore
	™	Application	International Japan Korea, Republic of (KR) Malaysia Taiwan
TARGA	®	Published Registered	United States of America China International Korea, Republic of (KR) Taiwan
Technology & Value SIGMAMELTEC (and Design)	®	Registered	United States of America China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America

Technology Enabled Services	®	Registered	International Japan United States of America
TEMPO	™ ®	Application Registered	China China European Union Taiwan United Kingdom
TERSA	®	Registered	China European Union International Korea, Republic of (KR) Taiwan United Kingdom
Tesseract	®	Registered	United States of America International Japan Korea, Republic of (KR) Singapore Taiwan
TETRA	™ ®	Application Registered	United States of America China China European Union International Japan Singapore Taiwan
THERMION	®	Registered	United States of America China International Korea, Republic of (KR) United States of America
THINK IT APPLY IT in Chinese	™ ®	Application Registered	China China
THINK SILICON	®	Registered	United States of America
Tiburon	®	Registered	European Union International

Tiburon	™	Allowed Application	United States of America China Japan Korea, Republic of (KR) Singapore Taiwan
TKM	®	Registered	United States of America
TKM TOTAL KIT MANAGEMENT	®	Registered	Taiwan
ToolTwin	® ™	Registered Application	International China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
TOPAZ	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
TOPBEAM	®	Registered	Benelux China France Germany (Federal Republic of) International Italy Japan Spain United Kingdom United States of America
TOPCOIL	®	Registered	China Italy Japan Korea, Republic of (KR) Latvia Taiwan

TopMet	®	Registered	China Germany (Federal Republic of) International Italy Spain United Kingdom
TOTAL KIT MANAGEMENT	®	Registered	United States of America
TotalConnect	®	Registered	European Union International Japan Singapore
	™	Allowed Application	United States of America China Israel Korea, Republic of (KR) Taiwan
TreatMag	®	Registered	Germany (Federal Republic of)
TRIDENT	®	Registered	Taiwan
TRILLIUM	®	Registered	Korea, Republic of (KR) Taiwan United States of America
Tripoli	®	Registered	European Union International Japan Singapore
	™	Allowed Application	Taiwan United States of America China Korea, Republic of (KR)
TrueTarget	®	Registered	China European Union International
	™	Allowed Application	United States of America Israel Japan Korea, Republic of (KR) Singapore Taiwan

TruFilm	®	Registered	United Kingdom
TruShape	®	Registered	China European Union Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom
	™	Application Published	International United States of America
TWIN CHAMBER	®	Registered	United States of America
Twin-AF-Mag	®	Registered	Benelux China Czechia Finland France Germany (Federal Republic of) Hungary India International Italy Japan Korea, Republic of (KR) Liechtenstein Poland Portugal Spain Sweden Switzerland Taiwan Turkey United Kingdom
TXZ	®	Registered	Korea, Republic of (KR) United States of America
ULTIMA HDP CVD	®	Registered	Japan Korea, Republic of (KR)
UniConnect	®	Registered	United States of America European Union

UniConnect	®	Registered	International Israel Singapore
	™	Allowed Application	United States of America China Japan Korea, Republic of (KR) Taiwan
UVISION	®	Registered	United States of America
VALAYA	®	Registered	Benelux International Singapore Sweden Switzerland United Kingdom
	™	Allowed Published	United States of America India
Valaya Design Mark	®	Registered	Benelux India International Singapore Sweden Switzerland United Kingdom
	™	Allowed	United States of America
VALAYA LIMITLESS EDGE (and Design)	®	Registered	Benelux International Singapore Sweden Switzerland United Kingdom
	™	Allowed Application	United States of America India
VANTAGE	®	Registered	United States of America
VANTAGE RADIANCE	®	Registered	China Korea, Republic of (KR) Taiwan
VANTAGE VULCAN	®	Registered	China

VANTAGE VULCAN	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
VARIAN	®	Registered	China
VARIAN CONTROL SYSTEM	®	Registered	United States of America
VARIAN POSITIONING SYSTEM	®	Registered	United States of America
VCS	®	Registered	China
VECTRA IMP SOURCE	®	Registered	United States of America
VENTARA	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
VERA	®	Registered	China European Union International Israel Taiwan United States of America
Veranome Biosystems	™	Application	Japan
VERICELL	®	Registered	United Kingdom
Veridian	®	Registered	United States of America
	™	Application To Be Filed	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
VERIPHI	™	Application To Be Filed	United States of America China European Union International Japan

VERIPHI	™	To Be Filed	Korea, Republic of (KR) Taiwan
VERITYSEM	®	Registered	United States of America
VERSITA	®	Registered	European Union International Japan Singapore Taiwan
	™	Allowed Application	United States of America China
VIISION	®	Registered	Korea, Republic of (KR) European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
VIISTA	®	Registered	China European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
Vistara	®	Registered	China European Union International Japan Taiwan United States of America
	™	Application	Korea, Republic of (KR) Singapore
VITA	®	Registered	China European Union International Israel Japan Korea, Republic of (KR)

VITA	®	Registered	Singapore Taiwan
VIVA	®	Registered	United States of America China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom
vMask	®	Registered	United States of America
VOLARIS	®	Registered	United States of America China International Japan Korea, Republic of (KR) Taiwan
VOLO FLOOD	®	Registered	United States of America China Taiwan
VOLO NEST	®	Registered	China Taiwan
VOLO PRINT	®	Registered	China Taiwan
VOLTA	®	Registered	China International Japan Korea, Republic of (KR) Taiwan
WaterAPC	®	Registered	United States of America United Kingdom
WaterMV	®	Registered	China International Singapore United Kingdom
WaterNeuron	®	Registered	United States of America United Kingdom
WIZER	®	Registered	United States of America

WORKSTREAM	®	Registered	China European Union International Japan United Kingdom United States of America
Xact	® ™	Registered Application	International China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Xsite	® ™	Registered Application	European Union International Singapore Taiwan United Kingdom United States of America Japan Korea, Republic of (KR)
ZEPHYR	® ™	Registered Allowed Application	China European Union International Singapore Taiwan United States of America United States of America Japan Korea, Republic of (KR)
各美讲堂 - Individual Beauty	®	Registered	China
應用材料.tw	®	Registered	Taiwan

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